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Synthesis by FVT and Characterization of Unhindered Silanethiones

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The retro-ene reaction of allylthio- and propargylthiosilanes led, under flash vacuum thermolysis (FVT) conditions, to unhindered silanethiones, characterized by their derivatives, and also directly by coupling of the FVT with gas-phase spectrometries. Monomeric silicon oxysulfide has been generated similarly. The unsubstituted silanethione was not obtained, but dehydrogenated into silicon monosulfide during FVT.

KEY WORDS: flash vacuum thermolysis, retro-ene, silanethione, silicon oxysulfide

The direct observation of silanethiones (R₂Si=S), when compared to other compounds possessing a double bond on silicon, remains particularly scarce, owing to their extreme thermodynamic and kinetic unstability.¹ Two silanethiones, stabilized either by intramolecular coordination² or by bulky substituents,^{3,4} have been however described. The unstabilized dimethylsilanethione has been generated by monomerization of its cyclotrimer under FVT conditions and characterized in the gas-phase by photoelectron spectrometry (PES).⁵

FVT is an excellent method of access to reactive, unhindered species having a silicon-heteroatom double bond⁶ and we report here our recent results concerning the obtention of simple silanethiones (1) by retro-ene reaction. The investigated precursors are allylthio- (2) and propargylthiodialkylsilanes (3), the latter being preferred for their lower temperatures of decomposition. Compounds 2 and 3 have been prepared by reaction of mercaptans with dialkylchlorosilanes in the presence of n-BuLi or NEt₃.

Dimethylsilanethione (1a) has been directly characterized by coupling of FVT with PES, showing the ionization potentials in agreement with those previously calculated and observed.⁵ The FVT-PES investigation of silanethiones 1b and 1c is presently in progress.⁷ 1b and 1c have been also identified by FVT-HRMS coupling. The generation

of silanethiones 1 has been confirmed by the obtention of cyclodimers 4a,b, cyclotrimer 5a, and of the cycloadduct 6a obtained in the cothermolysis of 3a with keten dimer [6a, δ^{1} H (CDCl₃): 0.43 (s, 6H), 4.40 and 4.57 (2d, J 1.7 Hz, 2H); δ^{13} C: -0.8, 94.7, 147.8].

Isobutene is easily eliminated from the t-butyl groups during the FVT of 2c (precluding in that case the obtention of 1c and 4c) and the formation of silanethione (7), a postulated interstellar molecule, was thus expected. An investigation in coupling with millimeter wave spectrometry (MWS) showed however the dehydrogenation of 7 at the FVT temperature and only silicon monosulfide (8) was obtained.⁸

The synthesis of silicon oxysulfide (9), another compound of cosmochemical importance, has been undertaken from precursor 10. The FVT of 10 showed the β -elimination of the t-butoxy groups and the competition of the retro-ene reaction giving 9 (characterized by its infrared spectrum at -196°C, in agreement with that reported in matrix⁹) with an α -elimination yielding silicon monoxide 11.8 Experiments aimed at the characterization of 9 by MWS are now in progress.¹⁰

SiO
$$\xrightarrow{\text{FVT, } 700 \, ^{\circ}\text{C}}$$
 $\xrightarrow{\text{Si } (\text{O-t-Bu})_2}$ $\xrightarrow{\text{FVT, } 700 \, ^{\circ}\text{C}}$ O=Si=S 11 $\xrightarrow{\text{- t-butanol}}$ $\xrightarrow{\text{- t-butanol}}$ 0=Si=S

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